

IN THE CLAIMS:

1. (Withdrawn)

2. (Withdrawn)

3. (Withdrawn)

4. (Withdrawn)

5. (Original) A method for producing a colloidal silica composition, the method comprising the steps of:

mixing and agitating an alkoxysilane compound, an organic solvent, deionized water, and a basic catalyst to produce colloidal silica;

washing the colloidal silica with deionized water to remove byproducts;

adding a basic organic material to the colloidal silica to adjust a hydrogen ion concentration (pH); and,

concentrating the pH-adjusted colloidal silica.

6. (Original) The method according to Claim 5, wherein the step of adding the basic organic material to adjust a hydrogen ion concentration is conducted before or after the step of washing the colloidal silica with deionized water to remove byproducts.

7. (Original) The method according to Claim 5, wherein the basic organic material is tetraethylammonium hydroxide.

8. (Original) The method according to Claim 5, wherein the basic catalyst is ammonia water.

9. (Withdrawn)

10. (Original) The method according to claim 5, further comprising the step of: applying a third heat treatment to remove organic materials.

11. (Withdrawn)

12. (Withdrawn)

13. (Withdrawn)

14. (Withdrawn)

15. (New) The method according to claim 5, wherein the basic organic material is added to the colloidal silica composition to the extent that the hydrogen ion concentration (pH) of colloidal silica becomes 12 or more.

16. (New) The method according to claim 5, wherein after concentrating the pH-adjusted colloidal silica, a concentration of the colloidal silica becomes 45% or more.

17. (New) The method according to Claim 5, wherein the basic organic material is added to the colloidal silica composition to the extent that the hydrogen ion concentration (pH) of colloidal silica becomes 12 to 12.8.